

<b>Notice of References Cited</b>	Application/Control No. 10/706,200	Applicant(s)/Pat nt Under Reexamination FABINSKI ET AL.	
	Examiner Zia R. Hashmi	Art Unit 2881	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-4,538,105	08-1985	Ausschnitt, Christopher P.	324/766
	B	US-6,335,151	01-2002	Ausschnitt et al.	430/322
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Brown et al., "High Quality Lithographic Processing", Pub. No: USD 2002/0045105 A1, publication date: April 18, 2002.
	V	
	W	
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.